

Supporting Information

Aqueous Processable WO_{3-x} Nanocrystals with Solution Tunable Localized Surface Plasmon Resonances

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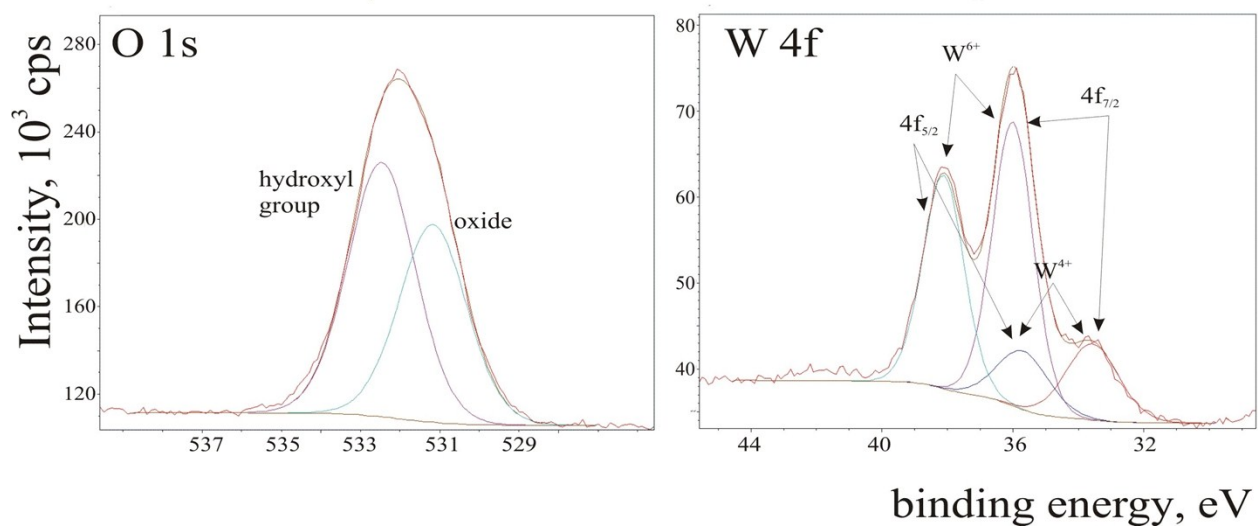


Figure S1. Detailed XPS scans of core O 1s and W 4f levels of the WO_{3-x} nanocrystals on a Si wafer.

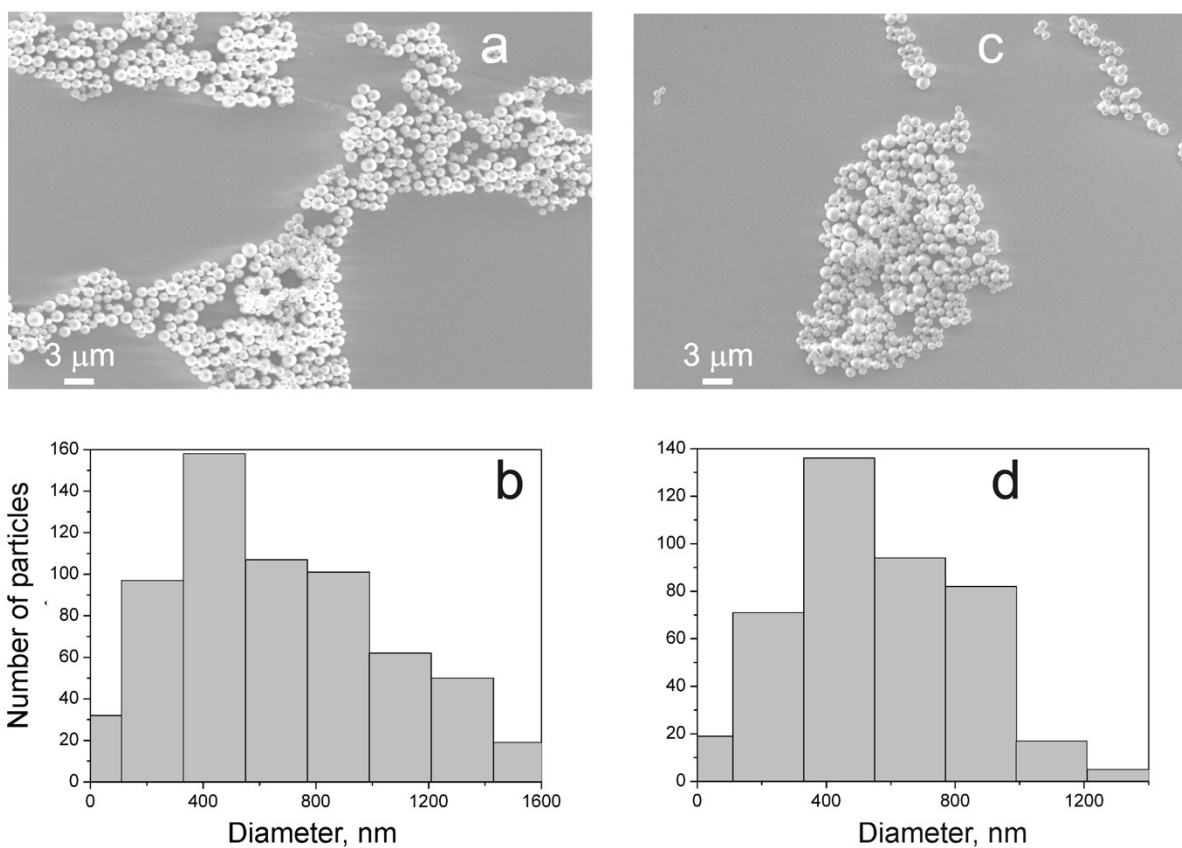


Figure S2. Representative SEM images and corresponding size histograms of the WO_{3-x} nanocrystals on a Si wafer deposited from water (a,b) and acidic solution (c,d) respectively.